

Notice of References Cited	Application/Control No. 10/572,718		Applicant(s)/Patent Under Reexamination FUJIWARA, YOSHIYASU	
	Examiner MANKO CHEUNG		Art Unit 4154	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-2002/0052716	05-2002	Fujiwara, Yoshiyasu	702/184
*	B	US-2002/0153004	10-2002	Agata, Takahiro	126/637
*	C	US-2004/0122602	06-2004	Nagase, Mamoru	702/051
*	D	US-6,880,128	04-2005	Nguyen, John H.	715/744
*	E	US-6,332,112	12-2001	Shukunami et al.	702/56
*	F	US-5,535,136	07-1996	Standifer, Larry R.	702/51
*	G	US-4,898,022	02-1990	Yumoto et al.	73/46
*	H	US-4,788,849	12-1988	Yonemura et al.	73/40.5A
*	I	US-4,727,750	03-1988	Yonemura, Masao	73/46
*	J	US-4,039,846	08-1977	Vance, James R.	290/4R
*	K	US-3,827,283	08-1974	Lerner et al.	73/40
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	WO 02066950 A1	08-2002	World Intellect	NAGASE M	
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	
	V	
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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